



ELECTRONIC COPY

LABORATORY GROWN DIAMOND REPORT

November 27, 2024	
IGI Report Number	LG666411160
Description	LABORATORY GROWN DIAMOND
Shape and Cutting Style	OVAL MODIFIED BRILLIANT
Measurements	9.10 X 6.55 X 4.44 MM

GRADING RESULTS

Carat Weight	2.08 CARATS
Color Grade	FANCY INTENSE YELLOW
Clarity Grade	VVS 2

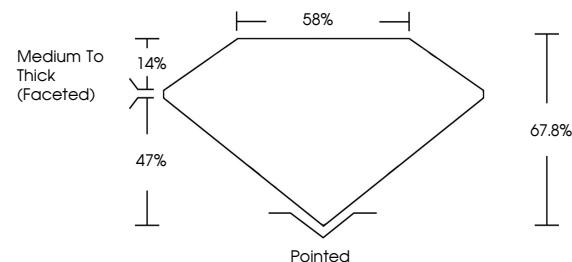
ADDITIONAL GRADING INFORMATION

Polish	EXCELLENT
Symmetry	EXCELLENT
Fluorescence	NONE
Inscription(s)	131 LG666411160

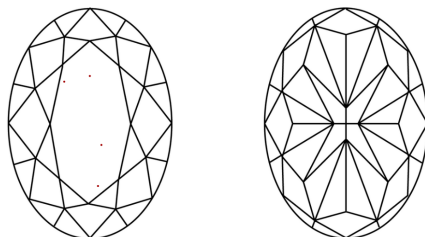
Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process.

LG666411160
Report verification at igi.org

PROPORTIONS



CLARITY CHARACTERISTICS



KEY TO SYMBOLS

Red symbols indicate internal characteristics.
Green symbols indicate external characteristics.



Sample Image Used

COLOR

D E F G H I J Faint Very Light Light

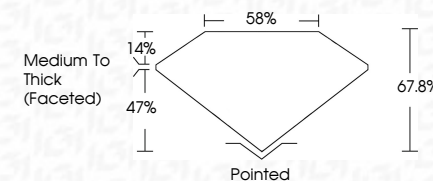
CLARITY

IF WS¹⁻² VS¹⁻² SI¹⁻² |¹⁻³

Internally Flawless	Very Very Slightly Included	Very Slightly Included	Slightly Included	Included
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November 27, 2024
GI Report No LG666411160
COVAL MODIFIED BRILLIANT

[illegible]

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